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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/944,665	08/31/2001	Toshiharu Furukawa	BUR919990305US1	3799
7590 12/03/2003 Whitham, Curtis & Christofferson, P.C. 11491 Sunset Hills Road, Suite 340			EXAMINER	
			LOKE, STEVEN HO YIN	
Reston, VA 20190			ART UNIT	PAPER NUMBER
			2811	
			DATE MAILED: 12/03/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)			
	09/944,665	FURUKAWA ET AL.			
Office Action Summary	Examin r	Art Unit			
	Steven Loke	2811			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply					
A SHORTENED STATUTORY PERIOD FOR RETHE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CF after SIX (6) MONTHS from the mailing date of this communication. If the period for reply specified above is less than thirty (30) days, If NO period for reply is specified above, the maximum statutory period for reply within the set or extended period for reply will, by set any reply received by the Office later than three months after the mearned patent term adjustment. See 37 CFR 1.704(b).	DN. R 1.136(a). In no event, however, may in. a reply within the statutory minimum of the reirod will apply and will expire SIX (6) Motatute, cause the application to become	a reply be timely filed nirty (30) days will be considered timely. DNTHS from the mailing date of this communication. ARANDONED (35.U.S.C. 8.133)			
1) Responsive to communication(s) filed on 2	28 October 2003.				
2a)☐ This action is FINAL . 2b)⊠ 1	This action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
 4) Claim(s) 1-44 is/are pending in the application. 4a) Of the above claim(s) 11-17 is/are withdrawn from consideration. 5) Claim(s) 1 and 6 is/are allowed. 6) Claim(s) 2-5, 18-44 is/are rejected. 7) Claim(s) 7-10 is/are objected to. Claim(s) are subject to restriction and/or election requirement. 					
Application Papers					
9) The specification is objected to by the Exam	niner.				
10)☐ The drawing(s) filed on is/are: a)☐		by the Examiner.			
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the co		• • • • • • • • • • • • • • • • • • • •			
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.					
Priority under 35 U.S.C. §§ 119 and 120					
12) Acknowledgment is made of a claim for for a) All b) Some * c) None of: 1. Certified copies of the priority docum 2. Certified copies of the priority docum 3. Copies of the certified copies of the papplication from the International Bu * See the attached detailed Office action for a 13) Acknowledgment is made of a claim for dom since a specific reference was included in the 37 CFR 1.78. a) The translation of the foreign language 14) Acknowledgment is made of a claim for dom reference was included in the first sentence of	pents have been received. Itents have been received in a priority documents have been reau (PCT Rule 17.2(a)). Itelist of the certified copies not estic priority under 35 U.S.C. et first sentence of the specific provisional application has lestic priority under 35 U.S.C.	Application No n received in this National Stage t received § 119(e) (to a provisional application) cation or in an Application Data Sheet. Deen received §§ 120 and/or 121 since a specific			
Attachment(s)					
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449) Paper Not 	5) Notice of	Summary (PTO-413) Paper No(s) Informal Patent Application (PTO-152)			

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- 1. Claims 5, 7-10, 21 and 35 are objected to because of the following informalities: Claim 5, line 2, the phrase "said gate structure" has no antecedent basis. Claim 7, line 1, the phrase "said gate structure" has no antecedent basis. Claim 8, line 3, the phrase "said insulator material" and line 4, the phrase "said pillar" have no antecedent basis. Claim 9, lines 3, 4, 5, the phrase "said pillar" and lines 4-5, the phrase "said gate structure" have no antecedent basis. Claim 10, line 2, the phrase "said gate structure" has no antecedent basis. Claim 21, line 1, the phrase "said gate" has no antecedent basis. Claim 35, line 2, the phrase "SOI" should be in full form. It should rewrite as "Silicon-on-insulator". Appropriate correction is required.
- 2. Claim 3 is rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention.

Fig. 37C discloses a borderless gate contact opening [3720] is formed through a resists [3710] and the nitride [3510]. The specification never discloses said at least one contact is formed in an opening in said isolation material adjacent said insulator material to a conductive region at an end of said pillar as claimed in claim 3. Only fig. 38C shows a borderless drain contact is formed in an opening in the isolation material [2620] adjacent said layer of insulator [3010] to a conductive region [2520, 3530] at an end of the pillar.

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3. Claims 2-5 and 18-44 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claim 2, lines 2-3, the phrase "isolation material adjacent said layer of insulator surrounding said vertical transistor" is unclear. It is believed that it should rewrite as "isolation material adjacent said layer of insulator and surrounding said vertical transistor".

Claim 4, line 5, the phrase "an insulating sidewall" is unclear whether it is similar to the sidewall of claim 1 (line 6).

Claim 5, line 2, the phrase "said trench" is unclear as to which trenches is it being referred to. There is more than one trench in claim 1 (line 3).

Claim 18, lines 3, 4, 5, 8, the phrase "first diffusion" is unclear whether it is being referred to "first diffusion region"; lines 4, 5, 6, the phrase "second diffusion" is unclear whether it is being referred to "second diffusion region".

- 4. Claims 1 and 6 are allowed.
- 5. Claim 18 would be allowable if rewritten or amended to overcome the rejection(s) under 35 U.S.C. 112, second paragraph, set forth in this Office action.
- 6. The following is a statement of reasons for the indication of allowable subject matter: The first major difference in the claims not found in the prior art of record is a vertical field effect transistor including at least one contact that is borderless to the gate electrodes. The second major difference in the claims not found in the prior art of record is an integrated circuit device including at least one contact that is borderless to

the gate electrode structure. The third major difference in the claims not found in the prior art or record is a transistor comprising a contact to the first diffusion region borderless to the gate structure.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Steven Loke whose telephone number is (703) 308-4920. The examiner can normally be reached on 7:50 am to 5:20 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie Lee can be reached on (703) 308-1690. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

sl December 1, 2003

Steen Loke